

## 650V SuperGaN™ FET in TO-247 (source tab)

#### Description

The TP65H035G4WS 650V, 35 m $\Omega$  gallium nitride (GaN) FET is a normally-off device using Transphorm's Gen IV platform. It combines a state-of-the-art high voltage GaN HEMT with a low voltage silicon MOSFET to offer superior reliability and performance.

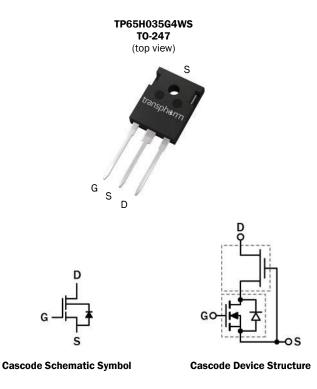
The Gen IV SuperGaN<sup>™</sup> platform uses advanced epi and patented design technologies to simplify manufacturability while improving efficiency over silicon via lower gate charge, output capacitance, crossover loss, and reverse recovery charge.

#### **Related Literature**

- AN0009: Recommended External Circuitry for GaN FETs
- AN0003: Printed Circuit Board Layout and Probing

### **Ordering Information**

Part Number	Package	Package Configuration
TP65H035G4WS	3 lead TO-247	Source



#### Features

- JEDEC qualified GaN technology
- Dynamic R<sub>DS(on)eff</sub> production tested
- Robust design, defined by
  - Wide gate safety margin
  - Transient over-voltage capability
- · Enhanced inrush current capability
- Very low QRR
- Reduced crossover loss

#### **Benefits**

- Enables AC-DC bridgeless totem-pole PFC designs
  - Increased power density
  - Reduced system size and weight
  - Overall lower system cost
- Achieves increased efficiency in both hard- and softswitched circuits
- · Easy to drive with commonly-used gate drivers
- GSD pin layout improves high speed design

#### Applications

- Datacom
- Broad industrial
- PV inverter
- Servo motor

### **Key Specifications**

V <sub>DSS</sub> (V)	650
V <sub>(TR)DSS</sub> (V)	725
$R_{DS(on)eff}(m\Omega)$ max*	41
Q <sub>RR</sub> (nC) typ	150
Q <sub>G</sub> (nC) typ	22

 $^{\ast}$  Dynamic on-resistance; ; see Figures 18 and 19

## Absolute Maximum Ratings (Tc=25°C unless otherwise stated.)

Symbol	Param	Parameter		Unit
V <sub>DSS</sub>	Drain to source voltage (T <sub>J</sub> = -	55°C to 150°C)	650	
V <sub>(TR)DSS</sub>	Transient drain to source volta	age <sup>a</sup>	725	V
V <sub>GSS</sub>	Gate to source voltage		±20	
PD	Maximum power dissipation @	Maximum power dissipation @Tc=25°C		W
1-	Continuous drain current @Tc=25°C		46.5	А
ID	Continuous drain current @Tc=100°C b		29.5	A
I <sub>DM</sub>	Pulsed drain current (pulse w	Pulsed drain current (pulse width: 10µs)		А
Tc	Operating temperature	Case	-55 to +150	°C
۲J		Junction	-55 to +150	°C
Ts	Storage temperature	Storage temperature		°C
TSOLD	Soldering peak temperature <sup>e</sup>		260	°C

Notes:

a. In off-state, spike duty cycle D<0.01, spike duration <1µs

b. For increased stability at high current operation, see Circuit Implementation on page 3

c. Continuous switching operation

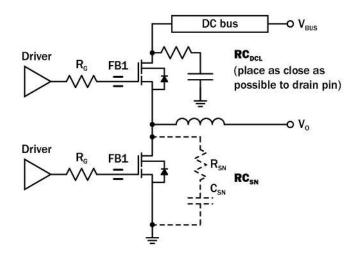
d.  $\leq$  300 pulses per second for a total duration  $\leq$  20 minutes

e. For 10 sec., 1.6mm from the case

#### **Thermal Resistance**

Symbol	Parameter	Typical	Unit
R <sub>ojc</sub>	Junction-to-case	0.8	°C/W
R <sub>OJA</sub>	Junction-to-ambient	40	°C/W

### **Circuit Implementation**





Recommended gate drive: (OV, 12V) with R\_G= 30  $\Omega$ 

Gate Ferrite Bead (FB1)	Required DC Link RC Snubber ( $RC_{DCL}$ ) <sup>a</sup>	Recommended Switching Node RC Snubber (RC <sub>SN</sub> ) <sup>b, c</sup>
$200-270\Omega$ at 100MHz	[4.7nF + 5Ω] x 2	Not necessary <b>b</b>

Notes:

a.  $\ensuremath{\mathsf{RC}_{\mathsf{DCL}}}$  should be placed as close as possible to the drain pin

b.  $RC_{SN}$  is needed only if  $R_G$  is smaller than recommendations

### **Electrical Parameters** (T<sub>J</sub>=25°C unless otherwise stated)

Symbol	Parameter	Min	Тур	Max	Unit	Test Conditions	
Forward D	Device Characteristics	I	1		1		
$V_{(BL)DSS}$	Drain-source voltage	650	_	_	V	V <sub>GS</sub> =0V	
$V_{\text{GS(th)}}$	Gate threshold voltage	3.3	4	4.8	V		
$\Delta V_{GS(th)}/T_J$	Gate threshold voltage temperature co- efficient	-	-6.5	_	mV/°C	V <sub>DS</sub> =V <sub>GS</sub> , I <sub>D</sub> =1mA	
R <sub>DS(on)eff</sub>	Drain-source on-resistance a	_	35	41	mΩ	$V_{GS}$ =10V, $I_{D}$ =30A	
TOS(on)eπ		_	72	—	11152	V <sub>GS</sub> =10V, I <sub>D</sub> =30A, T <sub>J</sub> =150°C	
I <sub>DSS</sub>	Drain-to-source leakage current	-	3	30	μA	V <sub>DS</sub> =650V, V <sub>GS</sub> =0V	
1055	Brain to source reakage current	-	20	_		V <sub>DS</sub> =650V, V <sub>GS</sub> =0V, T <sub>J</sub> =150°C	
	Gate-to-source forward leakage current	-	-	400	<b>P</b> ^	V <sub>GS</sub> =20V	
I <sub>GSS</sub>	Gate-to-source reverse leakage current	-	_	-400	nA	V <sub>GS</sub> =-20V	
CISS	Input capacitance	-	1500	_			
Coss	Output capacitance	_	147	_	pF	V <sub>GS</sub> =0V, V <sub>DS</sub> =400V, <i>f</i> =1MHz	
C <sub>RSS</sub>	Reverse transfer capacitance	_	5	_	-		
C <sub>O(er)</sub>	Output capacitance, energy related b	_	220	_	pF	$V_{GS}$ =0V, $V_{DS}$ =0V to 400V	
$C_{O(tr)}$	Output capacitance, time related °	_	380	_	рг		
$\mathbf{Q}_{\mathrm{G}}$	Total gate charge	_	22	_			
Q <sub>GS</sub>	Gate-source charge	_	8.4	_	nC	$V_{DS}$ =400V, $V_{GS}$ =0V to 10V, $I_{D}$ =32A	
$Q_{GD}$	Gate-drain charge	-	6.6	_			
Qoss	Output charge	_	150	_	nC	$V_{GS}$ =0V, $V_{DS}$ =0V to 400V	
t <sub>D(on)</sub>	Turn-on delay	_	60	_			
t <sub>R</sub>	Rise time	-	10	_	ns	$\begin{array}{ c c c c c c c c c c c c c c c c c c c$	
$t_{D(off)}$	Turn-off delay	-	94	_	115		
t <sub>F</sub>	Fall time	_	10	_	1		

Notes:

a. Dynamic on-resistance; see Figures 19 and 20 for test circuit and conditions

b. Equivalent capacitance to give same stored energy as  $V_{\text{DS}}$  rises from 0V to 400V

c. Equivalent capacitance to give same charging time as  $V_{\text{DS}}$  rises from OV to 400V

## Electrical Parameters (T<sub>J</sub>=25°C unless otherwise stated)

Symbol	Parameter	Min	Тур	Max	Unit	Test Conditions	
Reverse Dev	Reverse Device Characteristics						
I <sub>S</sub>	Reverse current	-	_	29.5	A	V <sub>GS</sub> =0V, T <sub>C</sub> =100°C ≤25% duty cycle	
V <sub>SD</sub>	Reverse voltage <sup>a</sup>	-	1.8	-	V	V <sub>GS</sub> =0V, I <sub>S</sub> =32A	
		_	1.3	_		V <sub>GS</sub> =0V, I <sub>S</sub> =16A	
t <sub>RR</sub>	Reverse recovery time	-	59	_	ns	I <sub>S</sub> =32A, V <sub>DD</sub> =400V,	
Q <sub>RR</sub>	Reverse recovery charge	_	150	_	nC	di/dt=1000A/ms	
(di/dt) <sub>RM</sub>	Reverse diode di/dt b	-	_	3200	A/µs	Circuit implementation and parameters on page 3	

Notes:

a. Includes dynamic R<sub>DS(on)</sub> effect

b. Reverse conduction di/dt will not exceed this max value with recommended R<sub>G</sub>.

## Typical Characteristics (Tc=25 °C unless otherwise stated)

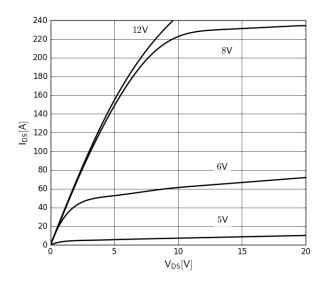
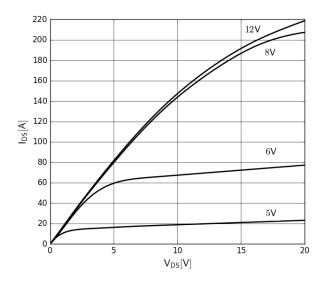
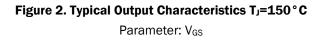
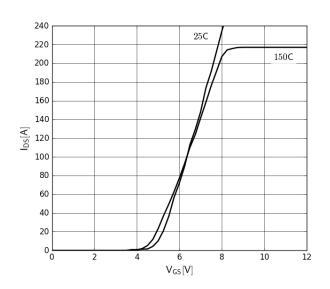
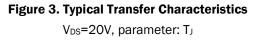


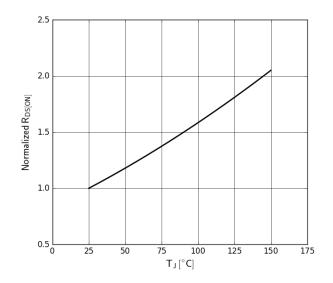
Figure 1. Typical Output Characteristics T\_J=25  $^{\circ}\text{C}$  Parameter:  $V_{\text{GS}}$ 

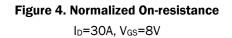




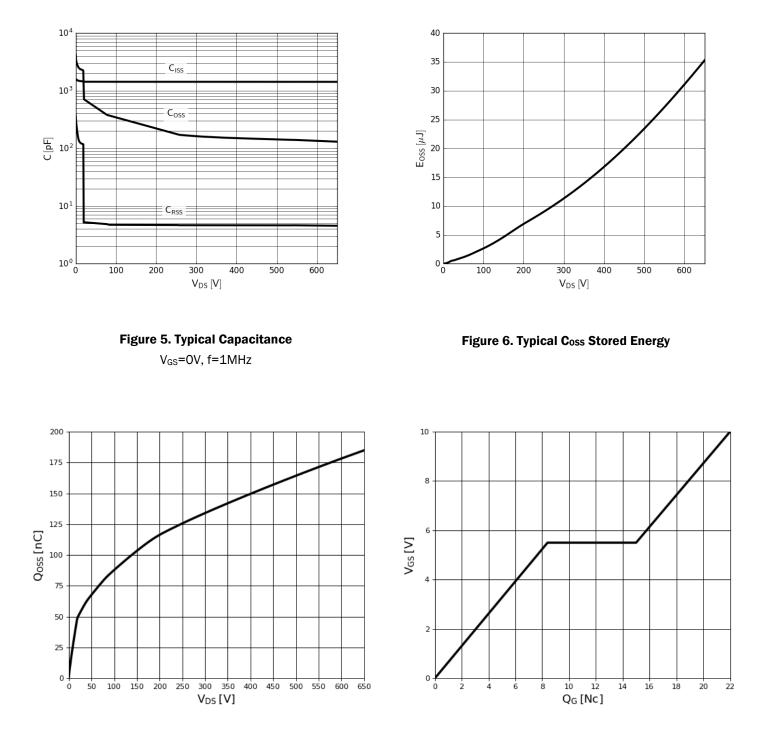


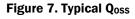






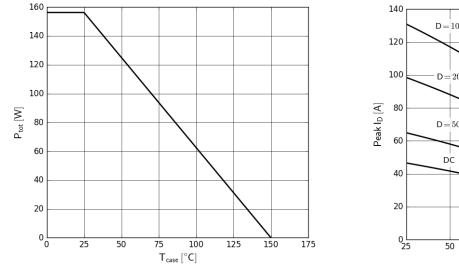
## Typical Characteristics (Tc=25 °C unless otherwise stated)







## Typical Characteristics (Tc=25 °C unless otherwise stated)



**Figure 9. Power Dissipation** 

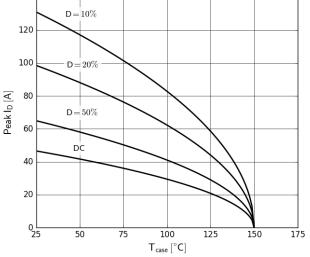
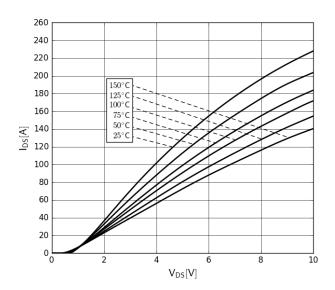
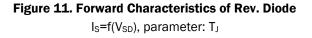


Figure 10. Current Derating Pulse width  $\leq 10\mu s$ ,  $V_{GS} \geq 10V$ 





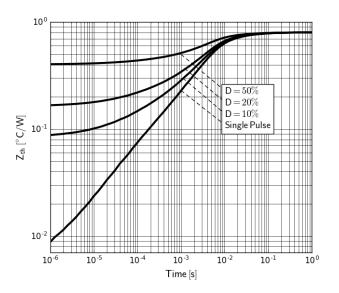


Figure 12. Transient Thermal Resistance

Typical Characteristics (Tc=25  $^{\circ}\text{C}$  unless otherwise stated)

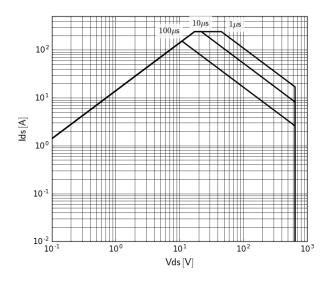


Figure 13. Safe Operating Area  $T_c=25$  °C

## **Test Circuits and Waveforms**

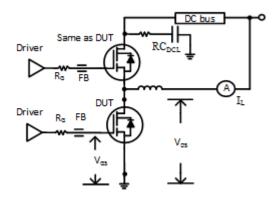


Figure 14. Switching Time Test Circuit (see circuit implementation on page 3 for methods to ensure clean switching)

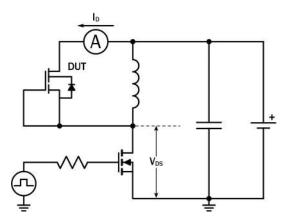


Figure 16. Diode Characteristics Test Circuit

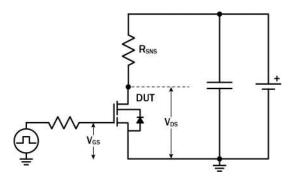


Figure 18. Dynamic RDS(on)eff Test Circuit

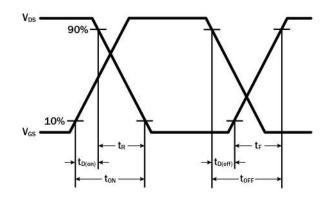


Figure 15. Switching Time Waveform

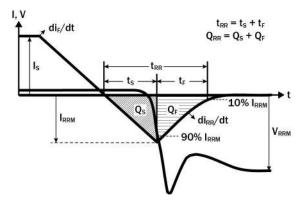
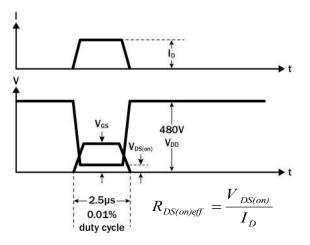


Figure 17. Diode Recovery Waveform





### **Design Considerations**

The fast switching of GaN devices reduces current-voltage crossover losses and enables high frequency operation while simultaneously achieving high efficiency. However, taking full advantage of the fast switching characteristics of GaN switches requires adherence to specific PCB layout guidelines and probing techniques.

Before evaluating Transphorm GaN devices, see application note <u>Printed Circuit Board Layout and Probing for GaN Power</u> <u>Switches</u>. The table below provides some practical rules that should be followed during the evaluation.

#### When Evaluating Transphorm GaN Devices:

DO	DO NOT
Minimize circuit inductance by keeping traces short, both in the drive and power loop	Twist the pins of TO-220 or TO-247 to accommodate GDS board layout
Minimize lead length of TO-220 and TO-247 package when mounting to the PCB	Use long traces in drive circuit, long lead length of the devices
Use shortest sense loop for probing; attach the probe and its ground connection directly to the test points	Use differential mode probe or probe ground clip with long wire
See AN0003: Printed Circuit Board Layout and Probing	

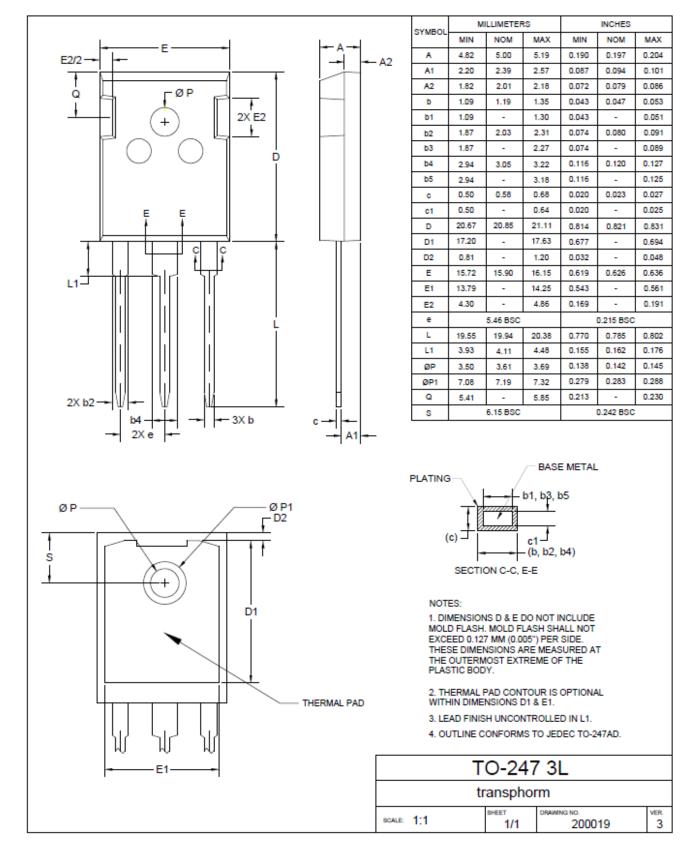
#### **GaN Design Resources**

The complete technical library of GaN design tools can be found at transphormusa.com/design:

- Evaluation kits
- Application notes
- Design guides
- Simulation models
- Technical papers and presentations

#### **Mechanical**

#### 3 Lead TO-247 Package



## **Revision History**

Version	Date	Change(s)	
0	1/17/2020	Preliminary Datasheet	
1	3/28/2020	Completed datasheet	
1.1	4/23/2020	Corrected Qg and Qg Curve	
1.2	4/29/2020	Updated Qoss Curve	